

CLAIMS

1. A low-reflection material comprising a transparent substrate, a hard coating layer provided on the transparent substrate, and a fluorine-containing polymer film provided on the hard coating layer,
wherein the hard coating layer contains ethylene oxide modified (meth)acrylate resin.
2. A low-reflection material comprising a transparent substrate, a hard coating layer provided on the transparent substrate, a high refractive index layer provided on the hard coating layer, and a fluorine-containing polymer film provided on the high refractive index layer,
wherein the high refractive index layer contains ethylene oxide modified (meth)acrylate resin.
3. The low-reflection material according to claim 1 or 2, wherein the ethylene oxide modified (meth)acrylate resin has three (meth)acryloyl groups or more in a monomer molecule.
4. The low-reflection material according to claim 1 or 2, wherein the fluorine-containing polymer film contains at least cured material of a radiation curable fluorine-containing a polymer having a carbon-carbon double bond in a side chain.